



Media Release

Pivotal Systems Establishes Scientific Advisory Board with Distinguished ALD Expert as First Member

Fremont, California and Sydney, Australia; 24 September 2021 – Pivotal Systems Corporation (“Pivotal” or the “Company”) (ASX: PVS), today announced the formation of an Advisory Board that will consist of internationally recognized experts who will bring depth of experience and leadership to the Company, including the appointment of its first member, Professor Stacey F. Bent, from Stanford University.

Pivotal’s new Advisory Board will institutionalize its approach to seeking expert, external perspectives on strategic initiatives across the Company. Pivotal’s research and development efforts will leverage the scientific expertise and deep business insight from this board of distinguished experts who have deep content knowledge on areas in which Pivotal is developing increased commercial presence.

John Hoffman, Pivotal Chairman and CEO, said, “For years, Pivotal’s core value proposition has been our innovative and forward-looking approach to precise gas flow control. We first made our mark in semiconductor manufacturing by demonstrating high-accuracy gas flow control for etching applications. Since then, we have continued to show value across new use cases, most prominently in semiconductor deposition processes. Today, we are assembling key experts across academia and the industry to serve on our Advisory Board and support our R&D team as we develop next generation products for our customers and pursue additional commercialization opportunities, such as our recently announced expansion into advanced gas flow control for battery manufacturing.”

Professor Stacey F. Bent, the founding member of the Advisory Board, brings considerable scientific insight and expertise in the field of Atomic Layer Deposition (ALD) to assist the Company. Professor Bent is the Jagdeep and Roshni Singh Professor at Stanford University, where she holds appointments as Vice Provost for Graduate Education and Postdoctoral Affairs, Professor of Chemical Engineering, and Professor, by courtesy, of Chemistry, of Materials Science and Engineering, and of Electrical Engineering. She is a globally recognized thought leader in surface and interfacial chemistry and holds many prestigious awards and positions, including winner of the American Vacuum Society 2021 ALD Innovator Award for original work and leadership in ALD, winner of the American Chemical Society 2018 Award in Surface Chemistry, election to the U.S. National Academy of Engineering, Fellow of the American Chemical Society, and Fellow of the American Vacuum Society, among others. At Pivotal, Professor Bent’s expertise will help guide research and development programs in ALD and related fields.

Joe Monkowski, Pivotal’s President, CTO, and founder, added, “Professor Bent’s appointment as the inaugural member of our Advisory Board supports Pivotal’s commitment to pushing the technological envelope. I have immense respect for what Professor Bent has accomplished in the world of ALD, where she is universally recognized as one of the field’s preeminent researchers. Pivotal will lean heavily on her expertise in surface chemistry and her subject matter expertise in semiconductor processing, electronics and renewable energy technologies.”

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About Pivotal Systems Corporation (ASX: PVS)

Pivotal Systems Corporation (ARBN 626 346 325), is a company incorporated in Delaware, USA, whose stockholders have limited liability. Pivotal Systems provides the best-in-class gas flow monitoring and control technology platform for the global semiconductor industry. The Company's proprietary hardware and software utilizes advanced machine learning to enable preventative diagnostic capability resulting in an order of magnitude increase in fab productivity and capital efficiency for existing and future technology nodes. For more information on Pivotal Systems Corporation, visit <https://www.pivotalsys.com/>.

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